



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

June 17, 2024

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG638440695

Report verification at [igi.org](#)

PROPORTIONS

Medium

62%

14%

51.5%

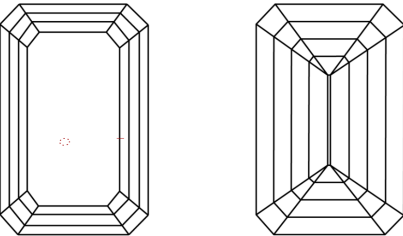
68.8%

Long



Sample Image Used

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

IF VS 1-2 VS 1-2 SI 1-2 I 1-3

Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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LABORATORY GROWN DIAMOND

EMERALD CUT

8.39 X 5.77 X 3.97 MM

1.90 CARAT

E

VS 1

EXCELLENT

EXCELLENT

NONE

 IGI

June 17, 2024

IGI Report No LG638440695

EMERALD CUT

8.39 X 5.77 X 3.97 MM

Carat Weight

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Depth

Table

Girdle

Culet

Polish

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1.90 CARAT

E

VS 1

68.8%

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Medium

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NONE



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